AMENDMENTS TO THE CLAIMS

(currently amended) A process for producing a polymer of ethylene containing from 0.1 to 99 % by mol of at least one derived unit of alpha-olefins of formula CH₂=CHZ, wherein Z is a C₂-C₂₀ alkyl radical, and optionally from 0 to 5% by mol polyene, comprising contacting, under polymerization conditions, ethylene, at least one alph-olefin and optionally said polyene, in the presence of a catalyst system obtained by contacting:

 a metallocene compound of formula (I):

$$R^3$$
 R^3
 R^3
 R^3
 R^3
 R^3
 R^2
 R^4
 R^3
 R^2
 R^3
 R^4
 R^3
 R^2
 R^3
 R^4
 R^3
 R^2
 R^3
 R^3
 R^2
 R^3
 R^3

(IV) or (V):

$$R^3$$
 R^4
 R^3
 R^2
 R^5
 R^6
 R^3
 R^4
 R^3
 R^4

$$R^3$$
 R^4
 R^3
 R^2
 R^5
 R^4
 R^6
 R^3
 R^3
 R^4
 R^3
 R^4

wherein

M is zirconium, hafnium or titanium;

X, equal to or different from each other, is a hydrogen atom, a halogen atom, an R, OR, OR'O, OSO₂CF₃, OCOR, SR, NR₂ or PR₂ group, wherein R is a linear or branched, saturated or unsaturated C₁-C₂₀-alkyl, C₃-C₂₀-cycloalkyl, C₆-C₂₀-aryl, C₇-C₂₀-alkylaryl, or C₇-C₂₀-arylalkyl radical, optionally containing at least one heteroatom belonging to groups 13-17 of the Periodic Table of the Elements; and the R' substituent is a divalent group selected from C₁-C₄₀-alkylidene, C₆-C₄₀-arylidene, C₇-C₄₀-alkylarylidene or C₇-C₄₀-arylalkylidene radicals; two X can join to form a C₄-C₄₀ dienyl ligand; R¹ is a linear or branched, saturated or unsaturated C₁-C₂₀-alkyl, C₃-C₂₀-cycloalkyl, C₆-C₂₀-aryl, C₇-C₂₀-alkylaryl, or C₇-C₂₀-arylalkyl radical, optionally containing at least one heteroatom belonging to groups 13-17 of the Periodic Table of the Elements; R², R³, R⁴ and R⁵, equal to or different from each other, are hydrogen atoms, halogen atoms linear or branched, saturated or unsaturated C₁-C₂₀-alkyl, C₃-C₂₀-cycloalkyl, C₆-C₂₀-aryl, C₇-C₂₀-alkylaryl, or C₇-C₂₀-arylalkyl radicals, optionally containing at least one heteroatom belonging to groups 13-17 of the Periodic Table of the Elements;

 R^3 is a hydrogen atom or a linear or branched, saturated or unsaturated C_1 - C_{10} -alkyl radical, optionally containing at least one halogen atom and R^4 is a hydrogen atom or a linear or branched, saturated or unsaturated C_1 - C_{10} -alkyl radical, optionally containing at least one halogen atom, wherein when R^3 is a hydrogen atom, R^4 is a linear or branched, saturated or unsaturated C_1 - C_{10} -alkyl radical, optionally containing at least one halogen atom, and when R^3 is a linear or branched, saturated or unsaturated C_1 - C_{10} -alkyl radical optionally containing at least one halogen atom, R^4 is a hydrogen atom;

 R^6 is a linear or branched, saturated or unsaturated C_1 - C_{20} -alkyl, C_3 - C_{20} -cycloalkyl, C_6 - C_{20} -aryl, C_7 - C_{20} -alkylaryl, or C_7 - C_{20} -arylalkyl radical, optionally containing at least one heteroatom belonging to groups 13-17 of the Periodic Table of the Elements;

L is a divalent bridging group selected from C_1 - C_{20} alkylidene, C_3 - C_{20} cycloalkylidene, C_6 - C_{20} arylidene, C_7 - C_{20} alkylarylidene, or C_7 - C_{20} arylalkylidene radicals, optionally containing heteroatoms belonging to groups 13-17 of the Periodic Table of the Elements, or a silylidene radical containing up to 5 silicon atoms;

T is a divalent radical of formula (II) or (III):

wherein

the atom marked with the symbol * is linked to the atom marked with the same symbol in the compound of formula (I);

R⁸-is a hydrogen atom or a linear or branched, saturated or unsaturated C₁-C₂₀-alkyl, C₃-C₂₀-eyeloalkyl, C₆-C₂₀-aryl, C₇-C₂₀-alkylaryl, or C₇-C₂₀-arylalkyl radical, optionally containing at least one heteroatom belonging to groups 13-17 of the Periodic Table of the Elements:

- R⁹, equal to or different from each other, is a hydrogen atom or a linear or branched, saturated or unsaturated C₁ C₂₀-alkyl, C₃ C₂₀-cycloalkyl, C₆ C₂₀-aryl, C₇ C₂₀-alkylaryl, or C₇ C₂₀-arylalkyl radical, optionally containing at least one heteroatom belonging to groups 13-17 of the Periodic Table of the Elements; and
- b) an alumoxane or a compound that forms an alkyl metallocene cation.
- 2. (original) The process according to claim 1 wherein the catalyst system further comprises an organo aluminum compound.
- 3. (currently amended) The process according to claim 1 wherein in the compound of formula (I)(IV) or (V),
 - X is a halogen atom, an R, OR'O or OR group; R¹ is a linear or branched, saturated or unsaturated C₁-C₂₀-alkyl radical; R² is a hydrogen atom; R³-is a hydrogen atom or a linear or branched, saturated or unsaturated C₁-C₂₀-alkyl radical optionally containing at least one halogen atom; R⁴-is a hydrogen atom or a linear or branched, saturated or unsaturated C₁-C₂₀-alkyl radical; R⁶ is a linear or branched, saturated or unsaturated C₁-C₂₀-alkyl radical; and L is Si(CH₃)₂, SiPh₂, SiPhMe, SiMe(SiMe₃), CH₂, (CH₂)₂, (CH₂)₃, C(CH₃)₂, C(Ph)₂ or C(CH₃)(Ph); R⁸-is hydrogen or a linear or branched, saturated or unsaturated C₁-C₂₀-alkyl radical; and R⁹-is hydrogen or a linear or branched, saturated or unsaturated C₁-C₂₀-alkyl radical.
- 4. (cancelled)
- (currently amended) The process according to claim [[4]]1 wherein, in the compounds of formula (IV) and (V), when R³ is a hydrogen atom, R⁴ is or a group -C(R³)3, wherein R³, equal to or different from each other, is a linear or branched, saturated or unsaturated C1-C8-alkyl radical; and when R⁴ is hydrogen, R³ is or a group -C(R³)3, wherein R³, equal to or different from each other, is a linear or branched, saturated or unsaturated C1-C8-alkyl radical
 - 6. (cancelled)
 - 7. (cancelled)
- (previously presented) The process according to claim 1 wherein the catalyst system is supported on an inert carrier.
- 6 -9. (previously presented) The process according to claim 8 wherein the inert carrier is a polyolefin.

- 10. (previously presented) The process according to claim 1 wherein the process is carried out in gas phase.
- 11. (previously presented) The process according to claim 1 wherein the alpha-olefin is 1-pentene, 1-hexene or 1-octene.
 - 12. (cancelled)
 - 13. (cancelled)